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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/054,826	01/23/2002	John Wasserbauer	47321/PAN/C715	7783
3017	7590	06/15/2004	EXAMINER	
BARLOW, JOSEPHS & HOLMES, LTD. 101 DYER STREET 5TH FLOOR PROVIDENCE, RI 02903			FLORES RUIZ, DELMA R	
			ART UNIT	PAPER NUMBER
			2828	

DATE MAILED: 06/15/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

**Office Action Summary**

Application No.

10/054,826

Applicant(s)

WASSERBAUER, JOHN10054826

Examiner

Delma R. Flores Ruiz

Art Unit

2828

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 02 April 2004.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-28 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-28 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- |                                                                                                                                               |                                                                                         |
|-----------------------------------------------------------------------------------------------------------------------------------------------|-----------------------------------------------------------------------------------------|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)                                                                   | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)                                                          | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)             |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)<br>Paper No(s)/Mail Date <u>4/2/2004</u> . | 6) <input type="checkbox"/> Other: _____                                                |

## DETAILED ACTION

### ***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1 – 28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jewell et al (5,719,894) in view of Hanke (6,584,130).

***Regarding claim 1***, Jewell disclose a surface emitting laser, comprising; an active region (see Fig. 9a – 10b Character 110), comprising a plurality of quantum wells (see Fig. 9b and 10b Character 16, and 128), formed between first mirror (see Fig. 9b , Character 102) and second mirror (see Fig. 9a Character 116), (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

Jewell discloses the claimed invention except for a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature.

Hanke teaches providing his device with a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser for the purpose of quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span share the same active region of the quantum wells.

It would have been obvious at the time of applicant's invention, to combine Hanke is teaching of a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser because the gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span share the same active region of the quantum wells, the optimum operating temperature for each element is very different. These results in a very narrow temperature region of the quantum wells, the optimum operating temperature for each element is very different. This results in a very narrow temperature region within which the operation of all the lasers can be achieved.

**Regarding claims 2, 23, 27,** Jewell disclose a thickness of said quantum wells varies from well to well so that transition energy and thereof gain peak wavelength varies from well to well or between groups of wells (Abstract, Column 16, Lines 16 –34, Column 17, Lines 19 – 29, and Column 19, Lines 26 - 46)

**Regarding claim 3,** Jewell disclose a material composition of said wells varies from well to wells to provide varying conduction and valence offset between the quantum wells and associated barriers layer (see Fig. 9b, Characters 54' and 70', Column 16, Lines 56 – 64).

**Regarding claim 4,** Jewell disclose an active region (see Fig. 9b and 10b, Character 110) further comprises a barrier layer (see Fig. 9b and 10b, Character 54' and 70') sandwiched between each of said quantum wells, wherein thickness of said barrier layers varies from barrier to barrier so that transition energy and therefore gain peak wavelength varies from well to well (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 5,** Jewell disclose an active region (see Fig. 9b and 10b, Character 110) further comprises a barrier layer (see Fig. 9b and 10b, Character 54' and 70') sandwiched between each of said quantum wells, wherein material composition of said barrier layer varies to barrier so that transition energy and therefore

gain peak wavelength varies from well to well or between groups of wells (Figs. 1 – 11, Abstract, Column 6, Lines 38 – 58, Column 16, Lines 16 –34, Column 17, Lines 19 – 29, and Column 19, Lines 26 - 46, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 6** Jewell disclose a material composition of said quantum wells varies from well to well to induce varying levels of strain from quantum well to quantum well to provide varying conduction and valence band offset between the quantum wells and associated barrier layers, Column 16, Lines 16 –34, Column 17, Lines 19 – 29, and Column 19, Lines 26 - 46, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 7 and 8**, Jewell disclose a quantum wells are gain matched such that the fraction of carriers contributing to stimulated emission is substantially constant over temperature and wherein thickness of said quantum wells decreases from well to well, such that each well operate at roughly the same internal efficiency  $\eta_i$  at different temperature (See Figs. 1 – 11, and Column 16, Lines 56 – 64).

**Regarding claim 9** Jewell, discloses an active region (see Fig. 9a – 10b Character 110) further comprises a barrier layer (see Fig. 9b and 10b Character 54' and 70') sandwiched between each of said quantum wells, wherein material composition of

said barrier layer varies from barrier layer to barrier layer, so that the barrier layer with greatest band offset provides majority of gain at a high operating temperature and the barrier layer with lowest band offset provides majority of gain at a low operating temperature (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 16, Lines 56 – 64, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 10** Jewell discloses a material composition of said quantum well varies from well to well to provide varying conduction and valence band offset between the quantum wells and associated barrier layers such that each well operate at roughly the same  $\eta_i$  and  $\eta$  at different temperature (See Figs. 1 – 11, and Column 16, Lines 56 – 64).

**Regarding claim 11**, Jewell disclose material composition of said quantum well varies from well to well to induce varying levels of strain from quantum well to quantum well such that quantum wells with the highest strain provides majority of gain at a high operating temperature and quantum well with lowest strain provides majority of gain at a low operating temperature (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 12**, Jewell disclose a first group of wells comprising a first number to wells provides majority of gain at a high operating temperature and a second

group of wells comprising a second number of wells provides majority of gain at a low operating temperature and wherein the first number of wells is greater than the second number of wells (see Figs. 1 – 11).

**Regarding claim 13,** Jewell disclose optical confinement factor varies from well to well levels such that the quantum well having largest optical confinement factor provides majority of gain at high operating temperature and the quantum well having the smallest optical confinement factor provides majority of gain at a low operating temperature (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 14,** Jewell disclose a laser further comprises an anode for injecting holes into said active region and wherein the quantum well that supplies majority of gain at a high operating temperature is closest to said anode and wherein the quantum well that supplies majority of gain at a low operating temperature is further from said anode (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 15,** Jewell disclose a level of non-radioactive recombination centers varies from well to well, and wherein the quantum well with least number of non-radioactive recombination centers provides majority of gain at a high operating



temperature and the quantum well with the most non-radioactive recombination centers provides majority of gain at a low operating temperature (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

***Regarding claim 16,*** Jewell disclose a method for forming an extended temperature range vertical cavity surface emitting laser (VCSEL), comprising the steps of: forming a first mirror (see Fig. 9a, Character 102); forming an active region (see Fig. 9a – 10b, Character 110) on said first mirror, and wherein said quantum wells are gained matched such that fraction of carrier that contribute to stimulated emission is substantially constant over temperature and forming a second mirror (see Fig. 9a Character 116) on said active region (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

Jewell discloses the claimed invention except for a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature.

Hanke teaches providing his device with a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser for the purpose of quantum wells is optimized to operate quasi-

independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span share the same active region of the quantum wells.

It would have been obvious at the time of applicant's invention, to combine Hanke of teaching a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser because the gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span share the same active region of the quantum wells, the optimum operating temperature for each element is very different. These results in a very narrow temperature region of the quantum wells, the optimum operating temperature for each element is very different. This results in a very narrow temperature region within which the operation of all the lasers can be achieved.

***Regarding claims 17 and 19,*** Jewell disclose the step of forming a plurality of gain separate quantum wells comprises forming a plurality of quantum wells (see Fig. 9b and 10b, Characters 126, and 128) having varying thickness (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 17, Lines 19 – 29, Column 19, Lines 26 – 46, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 18**, Jewell disclose a plurality of quantum wells having varying thickness comprises varying the thickness of said quantum well so that each well orb dominates operation of the surface emitting laser over a predetermined temperature range (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 20**, Jewell disclose the step of forming a plurality of quantum wells having varying gain enhancement factor comprises varying the gain enhancement factor of said quantum wells so that  $\eta$  is substantially constant over temperature (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

**Regarding claim 21**, Jewell disclose an extended temperature range vertical cavity surface emitting laser (VCSEL), comprising: a first mirror (see Fig. 9a, Character 102); an active region (see Fig. 9a – 10b, Character 110) on said first mirror, said active region being configured to provide a substantially constant stimulated emission at a cavity wavelength over an extended temperature range, said active region comprising a plurality of gain separated quantum wells each respectively configured to have a predetermined gain peak wavelength offset form said cavity wavelength, said a plurality of gain spattered quantum wells each respectively providing a dominant portion of said stimulated emission at said cavity wavelength at a predetermined temperature range

within said extended temperature range such that said VCSEL operates with a substantially constant stimulated emission at said cavity wavelength over said extended temperature range (see Fig. 9a Character 116) on said active region (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

Jewell discloses the claimed invention except for a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature.

Hanke teaches providing his device with a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser for the purpose of quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span share the same active region of the quantum wells.

It would have been obvious at the time of applicant's invention, to combine Hanke of teaching a gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature with surface emitting laser because the gain of each of said quantum wells is optimized to operate quasi-independently at different temperatures such that stimulated emission is dominated by a different quantum well at different temperature since all the lasers with a large wavelength span

share the same active region of the quantum wells, the optimum operating temperature for each element is very different. These results in a very narrow temperature region of the quantum wells, the optimum operating temperature for each element is very different. This results in a very narrow temperature region within which the operation of all the lasers can be achieved.

***Regarding claims 22, 24, 26 and 28,*** Jewell disclose quantum wells are gain matched such that the fraction of carrier contributing to stimulated emission is substantially constant over time and first group of wells comprising a first number of wells provides a dominant portion of stimulated emission at a high operating temperature, and a second group of wells comprising a second number of wells provides a dominant portion of stimulated emission at a low operating temperature, and wherein the first number of wells is greater than the second number of wells (Figs. 1 – 11, Abstract, Column 6, Lines 38 – 58, Column 16, Lines 53 – 67, Column 17, Lines 1 – 27, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

***Regarding claim 25,*** Jewell Regarding claim discloses the claimed invention except for close an extended temperature range vertical cavity surface emitting laser (VCSEL), comprising: a first mirror (see Fig. 9a, Character 102); an active region (see Fig. 9a – 10b, Character 110) on said first mirror, said active region being configured to provide a substantially constant stimulated emission at a cavity wavelength, said active region

comprising a plurality of gain separated quantum wells each respectively configured to have a predetermined gain peak wavelength offset from said cavity wavelength, said a plurality of gain spattered quantum wells each respectively providing a dominant portion of said stimulated emission at said cavity wavelength (see Fig. 9a Character 116) on said active region (Figs. 1 – 11, Column 6, Lines 38 – 58, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68) a first quantum well configured to have a first gain peak wavelength offset from said cavity wavelength, said first gain peak wavelength being a shorter than said cavity wavelength and longer than said first gain peak wavelength, a second quantum well configured to have a second gain peak wavelength offset from said cavity wavelength, said second gain peak wavelength being shorter than said cavity wavelength and longer than said first gain peak wavelength, said first and second quantum wells each respectively providing a dominant portion of said stimulated emission at said cavity wavelength (Figs. 1 – 11, Abstract, Column 6, Lines 38 – 58, Column 16, Lines 53 – 67, Column 17, Lines 1 – 27, Column 35, Lines 35 – 68, and Column 36, Lines 39 – 68).

### ***Response to Arguments***


Applicant's arguments filed 10/9/2003 have been fully considered but they are not persuasive. Applicant's arguments with respect to claims 1 – 28 have been considered but are moot in view of the new ground(s) of rejection.

### ***Conclusion***

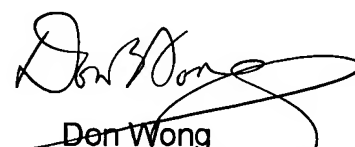
Any inquiry concerning this communication or earlier communications from the examiner should be directed to Delma R. Flores Ruiz whose telephone number is (571) 272-1940. The examiner can normally be reached on M - F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong can be reached on (571) -272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



Delma R. Flores Ruiz  
Examiner  
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DRFR/DW  
June 10, 2004